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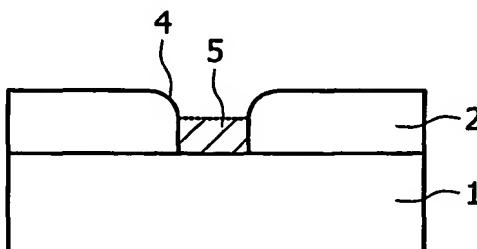
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(54) Title: A METHOD OF PRODUCING A CONDUCTIVE LAYER ON A SUBSTRATE



(57) Abstract: A method of producing a conductive layer (5) on a substrate (1) comprises depositing an insulator such as a photodefinition insulator (2) on the substrate (1), defining a groove (3) for the conductive layer (5) in the insulator material, filling the groove (3) with a precursor material and curing the material to provide the conductive layer.